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Docket No.: 1806.1003

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

Hiroshi YAMADA, et al.

Group Art Unit: 1752

Serial No. 10/514,411

Examiner: Connie P. Johnson

Filed: November 15, 2004

For: PHOTORESITIVE RESIN COMPOSITION FOR FORMING A LASER ENGRAVABLE PRINTING ELEMENT

STATEMENT OF SUBSTANCE OF INTERVIEW

Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

Sir:

On November 8, 2007, Examiner Johnson and her supervisor Examiner Kelly kindly discussed the application with the undersigned. The Examiners' time in preparing for and conducting the interview is acknowledged and gratefully appreciated.

An Examiner interview summary record was mailed on November 16, 2007. The summary indicates that the Examiner agreed to withdraw the rejections. Applicant's acknowledge and appreciate this thoughtful conclusion.

Respectfully submitted,

STAAS & HALSEY LLP

Date: Nov 29 2007

By: Mark J. Henry

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